

**DEVELOPMENT OF NONMETAL-DOPED TiO<sub>2</sub> NANOTUBE  
PHOTOCATALYST FOR DECOLORIZATION OF METHYL ORANGE**

**by**

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## TABLE OF CONTENTS

|  |        |
|--|--------|
| Acknowledgements.....  | ii     |
| Table of Contents.....   | iv     |
| List of Tables.....  | ix     |
| List of Figures.....   | xv     |
| List of Abbreviations.....                                       | xxix   |
| List of Symbols.....   | xxx    |
| Abstrak.....   | xxxii  |
| Abstract.....  | xxxiii |
| <br>   |        |
| CHAPTER 1 – INTRODUCTION   | 1      |
| 1.1 Introduction.....  | 1      |
| 1.2 Problem Statement.....                                       | 4      |
| 1.3 Research Objectives.....                                     | 6      |
| 1.4 Scope of Thesis.....   | 7      |
| 1.5 Project Outline.....   | 8      |
| <br>   |        |
| CHAPTER 2 – LITERATURE REVIEW                                    | 9      |
| 2.1 Properties of TiO <sub>2</sub> .....                         | 9      |
| 2.2 TiO <sub>2</sub> Nanostructure.....                          | 11     |
| 2.2.1 TiO <sub>2</sub> Nanoparticles.....                        | 12     |
| 2.3 Formation of TiO <sub>2</sub> Nanotubes Via Anodization..... | 15     |
| 2.3.1 First Generation of TiO <sub>2</sub> Nanotubes.....        | 15     |
| 2.3.2 Second Generation of TiO <sub>2</sub> Nanotube Arrays..... | 17     |

|                             |   |        |
|-----------------------------|---|--------|
| 2.3.3                       | Third Generation of TiO <sub>2</sub> Nanotube Arrays.....   | 19     |
| 2.4                         | Mechanistic Model of TiO <sub>2</sub> Nanotube Arrays Formation by Anodization.....                     | 21     |
| 2.5                         | Annealing.....  | 25     |
| 2.6                         | Modification Technique for Visible Light Harvesting.....  | 27     |
| 2.6.1                       | Metal Doping.....   | 28     |
| 2.6.2                       | Non-metal Doping.....   | 30     |
| 2.6.3                       | Technique of Doping.....  | 35     |
| 2.7                         | Photocatalysis.....   | 40     |
| 2.8                         | TiO <sub>2</sub> Photocatalyst.....   | 40     |
| 2.8.1                       | Mechanism of Pure, Metal doped and Non-metal Doped TiO <sub>2</sub> NT.....                             | 41     |
| 2.8.2                       | Photocatalytic Activity Mechanism.....  | 43     |
| <br>CHAPTER 3 – METHODOLOGY |   | <br>45 |
| 3.1                         | Introduction.....   | 45     |
| 3.2                         | Raw Materials.....  | 45     |
| 3.2.1                       | Chemicals.....  | 45     |
| 3.3                         | Experimental Procedure.....   | 47     |
| 3.3.1                       | Foil Preparation.....   | 47     |
| 3.3.2                       | Electrolyte Preparation.....  | 47     |
| 3.3.3                       | Formation of TiO <sub>2</sub> NT, C-TiO <sub>2</sub> NT and CP-TiO <sub>2</sub> NT via anodization..... | 48     |
| 3.3.4                       | Cleaning of the as-anodized TiO <sub>2</sub> NT.....  | 49     |
| 3.3.5                       | Formation of CP-TiO <sub>2</sub> NT via wet impregnation.....   | 49     |
| 3.3.6                       | Annealing.....  | 50     |

|                                   |  |    |
|-----------------------------------|--|----|
| 3.4                               | Experimental Design.....   | 50 |
| 3.4.1                             | Anodic growth of TiO <sub>2</sub> NT via anodization.....                      | 51 |
| 3.4.2                             | Doping of P <sup>5+</sup> into C-TiO <sub>2</sub> NT via wet impregnation..... | 53 |
| 3.5                               | Characterizations.....   | 54 |
| 3.5.1                             | Field emissions scanning electron microscope (FESEM).....                      | 54 |
| 3.5.2                             | Transmissions electron microscope (TEM).....                                   | 55 |
| 3.5.3                             | Energy dispersive X-ray analysis (EDX).....                                    | 56 |
| 3.5.4                             | X-ray photoelectron spectroscopy (XPS).....                                    | 57 |
| 3.5.5                             | X-ray diffraction analysis (XRD).....  | 58 |
| 3.5.6                             | Photoluminescence.....   | 59 |
| 3.5.7                             | UV-visible spectroscopy.....   | 59 |
| 3.6                               | Photocatalytic Activity Evaluation.....  | 60 |
| CHAPTER 4 – RESULT AND DISCUSSION |  | 62 |
| 4.1                               | Introduction.....  | 62 |
| 4.2                               | Formation of TiO <sub>2</sub> NT in Glycerol.....                              | 62 |
| 4.2.1                             | Effect of NH <sub>4</sub> F Amount on TiO <sub>2</sub> NT.....                 | 63 |
| 4.2.2                             | Effect of Anodization Time on TiO <sub>2</sub> NT.....                         | 65 |
| 4.2.3                             | Phase Formation and Crystal Structure.....                                     | 67 |
| 4.2.4                             | Chemical State and Electronic State.....                                       | 69 |
| 4.2.5                             | Structural Defect State.....   | 70 |
| 4.2.6                             | Photocatalytic Activity.....   | 71 |
| 4.2.6.1                           | Effect NT Diameter.....  | 71 |
| 4.2.6.2                           | Crystallinity Effect.....  | 72 |
| 4.3                               | Formation of C-TiO <sub>2</sub> NT by Anodization.....                         | 74 |

|         |   |     |
|---------|---|-----|
| 4.3.1   | Effect of Voltage on C-TiO <sub>2</sub> NT.....                                   | 74  |
| 4.3.1.1 | Roughness Factor.....   | 77  |
| 4.3.1.2 | Phase Formation and Crystal Structure.....  | 78  |
| 4.3.2   | Effect of Anodization Time on Surface Morphology of C-TiO <sub>2</sub> NT.....    | 80  |
| 4.3.3   | Effect of Water Addition on Surface Morphology of C-TiO <sub>2</sub> NT.....      | 82  |
| 4.3.3.1 | Phase Formation and Crystal Structure.....  | 87  |
| 4.3.3.2 | Crystallographic Structure.....   | 89  |
| 4.3.4   | Effect of Substrate Thickness on Surface Morphology of C-TiO <sub>2</sub> NT..... | 89  |
| 4.3.5   | Effect of Cleaning Agent on Surface Morphology of C-TiO <sub>2</sub> NT.....      | 91  |
| 4.3.6   | Surface Morphology of Reproducibility of C-TiO <sub>2</sub> NT.....               | 94  |
| 4.4     | Crystallization of TiO <sub>2</sub> NT Arrays.....                                | 97  |
| 4.4.1   | Effect of Annealing Temperature on Surface Morphology of TiO <sub>2</sub> NT..... | 97  |
| 4.4.2   | Effect of Annealing Atmosphere on Surface Morphology of TiO <sub>2</sub> NT.....  | 100 |
| 4.4.2.1 | Phase Formation and Crystal Structure.....  | 101 |
| 4.4.2.2 | Chemical State and Electronic State.....  | 102 |
| 4.4.2.3 | Structural Defect States.....   | 105 |
| 4.5     | Photocatalytic Activity.....  | 107 |
| 4.5.1   | Effect of Surface Structure of C – TiO <sub>2</sub> NT.....                       | 107 |
| 4.5.2   | Effect of the Aspect Ratio of C – TiO <sub>2</sub> NT.....                        | 110 |
| 4.5.3   | Effect of Wall Thickness of C – TiO <sub>2</sub> NT.....                          | 111 |
| 4.5.4   | Effect of Annealing Temperature.....  | 113 |
| 4.5.5   | Effect of Annealing Atmosphere.....   | 114 |

|   |   |     |
|---|---|-----|
| 4.6                                       | Formation of CP-TiO <sub>2</sub> NT.....  | 115 |
| 4.6.1                                     | Effect of Electrolyte Composition on Surface Morphology of CP-TiO <sub>2</sub> NT (anodization).....    | 115 |
| 4.6.1.1                                   | Phase Formation and Crystal Structure.....  | 120 |
| 4.6.2                                     | Effect of Voltage on Surface Morphology of CP-TiO <sub>2</sub> NT.....                                  | 121 |
| 4.6.2.1                                   | Phase Formation and Crystal Structure.....  | 123 |
| 4.6.3                                     | Effect of Annealing Atmosphere on Surface Morphology of CP-TiO <sub>2</sub> NT.....                     | 124 |
| 4.6.3.1                                   | Structural Defect States.....   | 125 |
| 4.6.4                                     | Photocatalytic Activity.....  | 126 |
| 4.6.5                                     | Effect of P Molarity on Surface Morphology of CP-TiO <sub>2</sub> NT (wet impregnation).....            | 127 |
| 4.6.5.1                                   | Phase Formation and Crystal Structure.....  | 130 |
| 4.6.6                                     | Effect of Impregnation Time on Surface Morphology of CP-TiO <sub>2</sub> NT.....                        | 132 |
| 4.6.6.1                                   | Phase Formation and Crystal Structure.....  | 137 |
| 4.6.6.2                                   | Chemical State and Electronic State.....  | 139 |
| 4.6.7                                     | Effect of Annealing Temperature on Phase Formation and Crystal Structure of CP-TiO <sub>2</sub> NT..... | 142 |
| 4.6.7.1                                   | Surface Morphology of CP-TiO <sub>2</sub> NT.....   | 146 |
| 4.7                                       | Photocatalytic Activity.....  | 148 |
| CHAPTER 5 – CONCLUSION AND RECOMMENDATION |   | 153 |
| 5.1                                       | Conclusion.....   | 153 |
| 5.2                                       | Recommendation.....   | 154 |
| References.....                           |   | 156 |
| Appendices                                |   |     |
| List of Publications                      |   |     |



## LIST OF TABLES

|           |   | <b>Page</b> |
|-----------|---|-------------|
| Table 2.1 | Band Gap Energy of Metal Oxide Photocatalysts (Hoffman et al., 1995).   | 11          |
| Table 2.2 | General TiO <sub>2</sub> Nanotubes Formation Via Anodization  | 20          |
| Table 2.3 | Doped TiO <sub>2</sub> prepared by sol-gel and hydrothermal method and their PC activity  | 36          |
| Table 2.4 | Doped TiO <sub>2</sub> prepared by thermal treatments method and their PC activity  | 37          |
| Table 2.5 | Doped TiO <sub>2</sub> prepared by sputtering method and their PC activity  | 38          |
| Table 2.5 | Doped TiO <sub>2</sub> prepared by sputtering method and their PC activity (continued)  | 39          |
| Table 2.6 | Doped TiO <sub>2</sub> prepared by immersion of TiO <sub>2</sub> NT in active electrolyte species and their PC activity             | 39          |
| Table 2.6 | Doped TiO <sub>2</sub> prepared by immersion of TiO <sub>2</sub> NT in active electrolyte species and their PC activity (continued) | 40          |
| Table 3.1 | General information of chemicals  | 46          |
| Table 3.2 | The parameters investigated on the formation of TiO <sub>2</sub> NT in glycerol   | 52          |

|           |  |    |
|-----------|--|----|
| Table 3.3 | The parameters investigated on the formation of C-TiO <sub>2</sub> NT in EG  | 52 |
| Table 3.3 | The parameters investigated on the formation of C-TiO <sub>2</sub> NT in EG (continued)  | 53 |
| Table 3.4 | The parameters investigated on the formation of CP-TiO <sub>2</sub> NT in EG/H <sub>3</sub> PO <sub>4</sub>  | 53 |
| Table 3.5 | The parameters investigated in wet impregnation to produce CP-TiO <sub>2</sub> NT and constant parameters used in this study   | 54 |
| Table 3.6 | The parameters investigated in photocatalytic activity evaluation  | 61 |
| Table 4.1 | The tube diameter, tube length and aspect ratio of Ti anodized in glycerol containing 0.24 wt% NH <sub>4</sub> F and 0.66 wt% NH <sub>4</sub> F at 30 V for 60, 180 and 360 min.   | 67 |
| Table 4.2 | PL bands of theoretical and experimental energies (eV) for TiO <sub>2</sub>  | 71 |
| Table 4.3 | Summary of the C-TiO <sub>2</sub> NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), surface roughness (G) and growth rate (μ) obtained at different anodization voltages for 60 min anodization in EG electrolyte containing 0.66 wt% NH <sub>4</sub> F | 77 |
| Table 4.4 | Refinement indexes of C-TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F at different anodization voltage and subsequent  | 80 |

annealed at 400 °C for 4 hr in Ar atmosphere.

|            |  |     |
|------------|--|-----|
| Table 4.5  | Summary of the C-TiO <sub>2</sub> NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), surface roughness (G) and growth rate ( $\mu$ ) obtained at 60 V in EG electrolyte containing 0.66 wt% NH <sub>4</sub> F for different anodization times.                         | 82  |
| Table 4.6  | Summary of the C-TiO <sub>2</sub> NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), surface roughness (G) and growth rate ( $\mu$ ) formed in EG electrolyte containing 0.66 wt% NH <sub>4</sub> F and different contents of H <sub>2</sub> O at 60 V for 60 min.     | 84  |
| Table 4.7  | Refinement indexes of C-TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F with various amount of H <sub>2</sub> O at 60 V for 60 min and subsequent annealed at 400 °C for 4 hr in Ar atmosphere.                | 88  |
| Table 4.8  | Refinement indexes of C-TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F, 1.0wt% H <sub>2</sub> O at 60 V for 60 min and subsequent annealed at annealing temperature (300 – 500 °C) for 4 hr in Ar atmosphere. | 89  |
| Table 4.9  | Refinement indexes of TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F, 1.0wt% H <sub>2</sub> O at 60 V and subsequent annealed at annealing temperature (600 – 700 °C) for 4 hr in Ar atmosphere.              | 99  |
| Table 4.10 | Refinement indexes of C-TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing   | 101 |

0.66 wt%  $\text{NH}_4\text{F}$ , 1.0wt%  $\text{H}_2\text{O}$  at 60 V and subsequent annealed at 500 °C for 4 hr in different atmosphere.

|            |  |     |
|------------|--|-----|
| Table 4.11 | Ratio of EG, $\text{H}_3\text{PO}_4$ and respective pH of the solution   | 116 |
| Table 4.12 | Summary of the CP- $\text{TiO}_2$ NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), surface roughness (G) and growth rate ( $\mu$ ) obtained at different volume fraction of EG: $\text{H}_3\text{PO}_4$ electrolyte containing 0.66 wt% $\text{NH}_4\text{F}$ for 1 hr anodization at 30 V.                            | 117 |
| Table 4.13 | Chemical stoichiometry of CP- $\text{TiO}_2$ NT in different volume fraction of EG: $\text{H}_3\text{PO}_4$ at 60 V for 60 min.  | 118 |
| Table 4.14 | Summary of the CP- $\text{TiO}_2$ NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), surface roughness (G) and growth rate ( $\mu$ ) obtained at different anodization voltages for 1 hr anodization in 90:10 (EG: $\text{H}_3\text{PO}_4$ ) electrolyte containing 0.66 wt% $\text{NH}_4\text{F}$                       | 123 |
| Table 4.15 | Summary of the CP- $\text{TiO}_2$ NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), and surface roughness (G) impregnated in different molarity of $\text{H}_3\text{PO}_4$ solution and subsequent annealing in Ar at 500 °C for 4 hr.  | 129 |
| Table 4.16 | Chemical stoichiometry of CP- $\text{TiO}_2$ NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% $\text{NH}_4\text{F}$ , 1.0wt% $\text{H}_2\text{O}$ at 60 V, wet impregnation in various molarity of $\text{H}_3\text{PO}_4$ for 60 min at 40 °C and subsequent annealed at 500 °C for 4 hr in Ar atmosphere. | 130 |
| Table 4.17 | Refinement indices of CP- $\text{TiO}_2$ NT arrays formed by   | 131 |

anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt%  $\text{NH}_4\text{F}$ , 1.0wt%  $\text{H}_2\text{O}$  at 60 V, wet impregnation in different molarity of  $\text{H}_3\text{PO}_4$  and subsequent annealed at 500 °C for 4 hr in Ar atmosphere.

|            |   |     |
|------------|---|-----|
| Table 4.18 | Summary of the CP-TiO <sub>2</sub> NT wall thickness (w), tube diameter (D), length (L), aspect ratio (AR), surface roughness (G) and growth rate ( $\mu$ ) obtained by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% $\text{NH}_4\text{F}$ , 1.0wt% $\text{H}_2\text{O}$ at 60 V, wet impregnation in 0.02 M $\text{H}_3\text{PO}_4$ at 40 °C for different impregnation time and subsequent annealed at 500 °C for 4 hr in Ar atmosphere | 133 |
| Table 4.19 | $\text{H}_3\text{PO}_4$ conditions upon wet impregnation of CP-TiO <sub>2</sub> NT in 0.02 M $\text{H}_3\text{PO}_4$ at 40 °C for different impregnation time   | 136 |
| Table 4.20 | Chemical stoichiometry of CP-TiO <sub>2</sub> NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% $\text{NH}_4\text{F}$ , 1.0wt% $\text{H}_2\text{O}$ at 60 V wet impregnation in 0.02 M $\text{H}_3\text{PO}_4$ at 40 °C for various impregnation time and subsequent annealed at 500 °C for 4 hr in Ar atmosphere.  | 136 |
| Table 4.21 | Refinement indexes of CP-TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% $\text{NH}_4\text{F}$ , 1.0wt% $\text{H}_2\text{O}$ at 60 V, wet impregnation in different molarity of $\text{H}_3\text{PO}_4$ and subsequent annealed at 500 °C for 4 hr in Ar atmosphere   | 141 |
| Table 4.22 | Refinement indexes of CP-TiO <sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% $\text{NH}_4\text{F}$ , 1.0wt% $\text{H}_2\text{O}$ at 60 V, wet impregnation in 0.02 M $\text{H}_3\text{PO}_4$ at 40 °C for 90 min and subsequent annealed at   | 144 |

different annealing temperature for 4 hr in Ar atmosphere.

- Table 4.23 Refinement indexes of CP-TiO<sub>2</sub> NT arrays formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH<sub>4</sub>F, 1.0wt% H<sub>2</sub>O at 60 V, wet impregnation in 0.02 M H<sub>3</sub>PO<sub>4</sub> at 40 °C for 90 min and subsequent annealed at different annealing temperature for 4 hr in Ar atmosphere. 144
- Table 4.24 Influence of P ion on the anatase to rutile phase transformation and the average size of anatase and rutile crystallite 146

## LIST OF FIGURES

|            |  | <b>Page</b> |
|------------|--|-------------|
| Figure 2.1 | Crystal structures of the rutile and anatase phases of TiO <sub>2</sub> (Gupta and Tripathi, 2011).  | 10          |
| Figure 2.2 | Classification of nanomaterials (a) 0D core shell nanoparticles, (b) 1D nanowires, nanorods, (c) 2D nanoplates, nanofilms and network, (d) 3D multilayers (Schodek et al., 2009)   | 12          |
| Figure 2.3 | (a) SEM image of TiO <sub>2</sub> nanotubes and (b) TEM image of TiO <sub>2</sub> nanotubes (Kasuga et al., 1998)  | 14          |
| Figure 2.4 | FESEM images of Ti anodized at 20 V in H <sub>2</sub> SO <sub>4</sub> (1 M) 1 HF ~0.15 wt % for 24 h (a) top view of TiO <sub>2</sub> nanotubes. (b) cross-sectional view of TiO <sub>2</sub> nanotubes (Beranek et al., 2003).  | 14          |
| Figure 2.5 | FESEM top view images of porous TiO <sub>2</sub> films anodized in 0.066 wt% HF for 20 minutes under different voltage (a) 3 V, (b) 5 V, (c) 10 V and (d) 20 V. inset in image (d) is a cross-sectional view (Gong et al., 2001) | 16          |
| Figure 2.6 | Cross-sectional view of TiO <sub>2</sub> nanotubes formed in (a) pH 2.8 and (b) pH 4.5. Inset in (a) shows the pore size with anodization potential of 25 V (Cai et al., 2005)   | 18          |
| Figure 2.7 | FESEM of (a) top image, and (b) cross-sectional of TiO <sub>2</sub> nanotube arrays grown at 60 V in an EG electrolyte. (Shankar et al., 2007)   | 20          |

- Figure 2.8 Schematic diagram of formation of titania nanotube arrays 23  
(a) oxide layer formation, (b) burst of oxide by the formation of crystallites (pore formation), (c) growth of the pores due to field assistant dissolution of titania, (d) immediate repassivation of pore tips, (e) voids formation in the metallic part between the pores, (f) formation of nanotubes of titania, (g) burst of repassivated oxide, (h) formation of new pores inside existing pores (Zhao et al., 2005a).
- Figure 2.9 Schematical (left column) and SEM sequence (top-views – middle column, cross-sections – right column) of different stages of the TiO<sub>2</sub> nanotube layer formation. Anodization stopped after (a) 0 min, (b) 3 min, (c) 10 min, from reaching 20 V in water/glycerol/0.27M NH<sub>4</sub>F after potential ramp from 0 to 20 V with a sweep rate of 250 mV/s (Macak et al., 2008). 24
- Figure 2.10 Schematical (left column) and SEM sequence (top-views – middle column, cross-sections – right column) of different stages of the TiO<sub>2</sub> nanotube layer formation. Anodization stopped after (c) 30 min, (d) 60 min from reaching 20 V in water/glycerol/0.27M NH<sub>4</sub>F after potential ramp from 0 to 20 V with a sweep rate of 250 mV/s (Macak et al., 2008). 25
- Figure 2.11 Schematic representation of the crystallization of the TiO<sub>2</sub> NT arrays: (a) nucleation of anatase crystals at temperatures around 280 °C; (b) growth of the anatase crystals at elevated temperatures; (c) nucleation of rutile crystals at around 430 °C; (d) growth of rutile crystals at higher temperatures (the anatase crystals in the walls in contact with rutile crystals in the interface region are transformed to rutile at temperatures above approximately 480 °C); (e) complete transformation of crystallites in the walls to rutile at temperatures above 27



approximately 620 °C (Varghese et al., 2003a)

|             |   |    |
|-------------|---|----|
| Figure 2.12 | Schematic diagram showing the VB and CB of three different forms of N-doped anatase TiO <sub>2</sub> (Dunnill and Parkin, 2011).  | 31 |
| Figure 2.13 | Mechanism of TiO <sub>2</sub> photocatalysis: fiv1: pure TiO <sub>2</sub> NT, fiv2: metal-doped TiO <sub>2</sub> NT, fiv3: non-metal doped TiO <sub>2</sub> NT (Zaleska et al., 2008)                   | 43 |
| Figure 3.1  | Diagram illustrating the components of the anodizing unit. The system includes a two electrodes cell and a power supply, remotely controlled by a laptop.   | 48 |
| Figure 3.2  | Annealing profile of TiO <sub>2</sub> NT  | 50 |
| Figure 3.3  | Flow chart of overall process in this research study.   | 51 |
| Figure 3.4  | Methodology flow chart for anodization process.   | 52 |
| Figure 4.1  | The top view and cross section view of TiO <sub>2</sub> NT formed in glycerol containing 0.24 wt% NH <sub>4</sub> F and 0.66 wt% NH <sub>4</sub> F at 30 V for 60 min                                   | 64 |
| Figure 4.2  | Current density versus time plot during anodization of Ti in glycerol containing (a) 0.24 wt% NH <sub>4</sub> F and (b) 0.66 wt% NH <sub>4</sub> F at 30 V for 60 min.                                  | 65 |
| Figure 4.3  | FESEM images of oxide layers after anodization in glycerol containing 0.24 wt% NH <sub>4</sub> F and 0.66 wt% NH <sub>4</sub> F at 30 V for 180 and 360 min. The insets show the top view of respective | 67 |

morphologies.

- Figure 4.4 XRD patterns of (a) as-anodized  $\text{TiO}_2$  NT prepared in glycerol with 0.24 wt%  $\text{NH}_4\text{F}$ , and  $\text{TiO}_2$  NT prepared in glycerol with (b) 0.24, (c) 0.66 wt%  $\text{NH}_4\text{F}$  at 30 V for 1 hr after annealing at 400 °C for 4 hr in argon. The insets show the magnified patterns of (101) peak. 68
- Figure 4.5 XPS spectra of  $\text{TiO}_2$  NT prepared in glycerol with 0.24 wt%  $\text{NH}_4\text{F}$  at 30 V for 60 min (a) as-anodized and (b) after annealing at 400 °C for 4 hr in argon. 69
- Figure 4.6 PL spectra and their Gaussian fit band of  $\text{TiO}_2$  NT prepared in glycerol with (a) 0.24 wt%  $\text{NH}_4\text{F}$ , (b) 0.66 wt%  $\text{NH}_4\text{F}$  at 30 V for 60 min after annealing at 400 °C for 4 hr in argon (excitation wavelength = 325 nm). 71
- Figure 4.7 MO decolorization using  $\text{TiO}_2$  NT prepared in glycerol with 0.24 wt%  $\text{NH}_4\text{F}$ , and 0.66 wt%  $\text{NH}_4\text{F}$  at 30 V for 60 min after annealing at 400 °C for 4 hr in argon. 72
- Figure 4.8 MO decolorization using  $\text{TiO}_2$  NT prepared in glycerol with 0.24 wt%  $\text{NH}_4\text{F}$  at 30 V for 1 hr (a) as-anodized and (b) after annealing at 400 °C for 4 hr in argon. 73
- Figure 4.9 (A) Current density versus time plot during anodization of Ti in EG electrolyte containing 0.66 wt%  $\text{NH}_4\text{F}$  for 60 min at (a) 40 V, (b) 50 V, (c) 60 V, (d) 80 V and (e) 100 V and (B) the first three min of current density-time plot 75
- Figure 4.10 FESEM images of C- $\text{TiO}_2$  NT formed in EG electrolyte containing 0.66 wt%  $\text{NH}_4\text{F}$  for 60 min at (a) 40, (b), 50, (c) 76

60, (d) 80 and (e) 100 V. The inset shows the cross-section view of respective morphologies. (FESEM images taken after annealing at 400 °C for 4 hr in argon atmosphere)<sup>77</sup>

- Figure 4.11 Idealized unit cell of TiO<sub>2</sub> NT array with inner diameter D, wall-thickness w, and  $a = D + 2w$ . 77
- Figure 4.12 XRD patterns of (a) as-anodized C-TiO<sub>2</sub> NT formed in EG electrolyte containing 0.66 wt% NH<sub>4</sub>F at 60 V for 60 min and C-TiO<sub>2</sub> NT prepared in EG electrolyte containing 0.66 wt% NH<sub>4</sub>F at (b) 40 V, (c) 50 V, (d) 60 V, (e) 80 V and (f) 100 V for 60 min after annealed in Ar atmosphere for 4 hr at 400 °C. 80
- Figure 4.13 FESEM images of C-TiO<sub>2</sub> NT prepared in EG electrolyte containing 0.66 wt% NH<sub>4</sub>F at 60 V for (a) 1, (b) 15 min. The insets show the cross-section view of respective morphologies. 81
- Figure 4.13 FESEM images of C-TiO<sub>2</sub> NT prepared in EG electrolyte containing 0.66 wt% NH<sub>4</sub>F at 60 V for (c) 20, (d) 30 min, (e) 180 and (f) 360 min. The insets show the cross-section view of respective morphologies. (continued) 82
- Figure 4.14 FESEM images of C-TiO<sub>2</sub> NT prepared in EG solution containing 0.66 wt% NH<sub>4</sub>F, and (a) 0.45, (b) 0.89 wt% H<sub>2</sub>O at 60 V for 60 min. The insets show the top view of respective morphologies. (FESEM images taken after annealing at 400 °C for 4 hr in argon atmosphere). 83
- Figure 4.14 FESEM images of C-TiO<sub>2</sub> NT prepared in EG solution containing 0.66 wt% NH<sub>4</sub>F, and (c) 1.33 and (d) 1.76 wt% 84

H<sub>2</sub>O at 60 V for 60 min. The insets show the top view of respective morphologies. (FESEM images taken after annealing at 400 °C for 4 hr in argon atmosphere).  
(continued)

- Figure 4.15 XRD patterns of (a) as-anodized (b) C-TiO<sub>2</sub> NT prepared in EG electrolyte containing 0.66 wt% NH<sub>4</sub>F and (c) 0.45, (d) 0.89, (e) 1.33, (f) 1.67 wt% of H<sub>2</sub>O at 60 V for 60 min after annealed in Ar atmosphere for 4 hr at 400 °C. 88
- Figure 4.16 (a) TEM image and (b) HRTEM image of C-TiO<sub>2</sub> NT prepared in EG solution containing 0.66 wt% NH<sub>4</sub>F and 0.89 wt% H<sub>2</sub>O at 60 V for 1 hr and subsequent annealing at 400 °C for 4 hr in Ar atmosphere. 89
- Figure 4.17 FESEM images of C-TiO<sub>2</sub> NT formed on (a) 0.03, (b) 0.05 and (c) 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH<sub>4</sub>F, and 1.0wt% H<sub>2</sub>O at 60 V for 60 min. The insets show the top view of respective morphologies. (FESEM images taken after annealing at 400 °C for 4 hr in argon atmosphere). 90
- Figure 4.18 Current density versus time plot during anodization of (a) 0.03, (b) 0.05, (c) 0.1 mm thick Ti foil in EG electrolyte containing 0.66 wt% NH<sub>4</sub>F and 0.24 wt% H<sub>2</sub>O at 60 V for 60 min. 91
- Figure 4.19 FESEM images of C-TiO<sub>2</sub> NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH<sub>4</sub>F, and 1.0wt% H<sub>2</sub>O at 60 V for 60 min after ultrasonically cleaned in (a) DI water, (b) acetone, and air dried. The insets show the cross-section view of respective morphologies. 93

|             |   |     |
|-------------|---|-----|
| Figure 4.19 | FESEM images of C-TiO <sub>2</sub> NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F, and 1.0wt% H <sub>2</sub> O at 60 V for 60 min after ultrasonically cleaned in (c) DI water, (d) acetone, and dry under N <sub>2</sub> gas flow. The insets show the cross-section view of respective morphologies. (continued)   | 94  |
| Figure 4.20 | Current density versus time plot during anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F, and 1.0wt% H <sub>2</sub> O at 60 V for 60 min (a) fresh electrolyte, (b) 1st used electrolyte, (c) 2nd used electrolyte and (d) 3rd used electrolyte.  | 95  |
| Figure 4.21 | FESEM images of C-TiO <sub>2</sub> NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH <sub>4</sub> F, and 1.0wt% H <sub>2</sub> O at 60 V for 60 min (a) fresh electrolyte, (b) 1st used electrolyte, (c) 2nd used electrolyte and (d) 3rd used electrolyte. The insets show the cross-section view of respective morphologies.   | 96  |
| Figure 4.22 | FESEM top-view images and cross-section (inset) of C-TiO <sub>2</sub> NT annealed in argon atmosphere for 4 hr at (a) 300 °C, (b) 400 °C, (c) 500 °C, (d) 600 °C, (e) 700 °C and their respective XRD pattern. The inset in (a) – (c) show the cross-section view of respected images while the inset in (d) show the low magnification image of rutile protrusion emerging from Ti substrate and inset in (e) show the low magnification image of the collapsed structure. | 98  |
| Figure 4.23 | FESEM images of (a) as-prepared C-TiO <sub>2</sub> NT and C-TiO <sub>2</sub> NT annealed at 500 °C for 4 hr in (b) Ar, (c) N <sub>2</sub> and (d) O <sub>2</sub> atmosphere. The inset shows the top view of respective   | 100 |

morphologies.

|             |  |     |
|-------------|--|-----|
| Figure 4.24 | (A) XRD spectra and (B) XRD pattern of the 25.3° reflection (a) as-prepared C-TiO <sub>2</sub> NT and C-TiO <sub>2</sub> NT annealed at 500 °C for 4 hr in (b) Ar, (c) N <sub>2</sub> and (d) O <sub>2</sub> atmosphere. | 101 |
| Figure 4.25 | XPS spectra of C-TiO <sub>2</sub> NT annealed at 500 °C for 4 hr in (a) Ar, (b) N <sub>2</sub> and (c) O <sub>2</sub> atmosphere.  | 104 |
| Figure 4.26 | VBM of C-TiO <sub>2</sub> NT annealed at 500 °C for 4 hr in (a) Ar, (b) N <sub>2</sub> and (c) O <sub>2</sub> atmosphere.  | 104 |
| Figure 4.27 | PL spectra of C-TiO <sub>2</sub> NT annealed at 500 °C for 4 hr in (a) Ar, (b) N <sub>2</sub> and (c) O <sub>2</sub> atmosphere.   | 106 |
| Figure 4.28 | Schematic diagram of comparison of the e <sup>-</sup> transfer pathways of C-TiO <sub>2</sub> NT annealed at 500 °C for 4 hr in (a) Ar, N <sub>2</sub> and (b) O <sub>2</sub> atmosphere.                                | 107 |
| Figure 4.29 | Effect of surface structures of C-TiO <sub>2</sub> NT films on photocatalytic decolorization of MO solution under visible light irradiation (Co = 30 ppm)  | 108 |
| Figure 4.30 | Effect of C-TiO <sub>2</sub> NT length on the photocatalytic decolorization of MO solution under visible light irradiation (Co = 30 ppm)   | 110 |
| Figure 4.31 | Effect of C-TiO <sub>2</sub> NT wall thickness on the photocatalytic decolorization of MO solution under visible light irradiation (Co = 30 ppm)   | 111 |

|             |  |     |
|-------------|--|-----|
| Figure 4.32 | Dependence of rate constant ( $k$ ) of C-TiO <sub>2</sub> NT on the annealing temperature  | 113 |
| Figure 4.33 | Dependence of rate constant ( $k$ ) of TiO <sub>2</sub> NT on the annealing atmosphere.  | 114 |
| Figure 4.34 | FESEM images of CP-TiO <sub>2</sub> NT formed in different volume fraction of EG:H <sub>3</sub> PO <sub>4</sub> , (a) P1, (b) P2, (c) P3, (d) P4 and (d) P5. The insets show the cross-section view of respective morphologies.  | 116 |
| Figure 4.35 | Current density versus time plot of Ti anodized at various electrolyte composition, (a) P1, (b) P2, (c) P3, (d) P4 and (e) P5.   | 119 |
| Figure 4.36 | XRD patterns of CP-TiO <sub>2</sub> NT formed in formed in different volume fraction of EG:H <sub>3</sub> PO <sub>4</sub> and subsequent annealing in argon atmosphere at 400 °C for 4 hr, (a) P2, (b) P3, (c) P4 and (d) P5.  | 121 |
| Figure 4.37 | FESEM images of CP-TiO <sub>2</sub> NT formed in 90:10 (EG:H <sub>3</sub> PO <sub>4</sub> ) electrolyte containing 0.66 wt% NH <sub>4</sub> F for 60 min at (a) 30, (b), 40, (c) 50 and (d) 60 V. The inset shows the cross-section view of respective morphologies. (FESEM images taken after annealing at 400 °C for 4 hr in argon atmosphere) | 122 |
| Figure 4.38 | XRD patterns of CP-TiO <sub>2</sub> NT prepared in 90:10 (EG:H <sub>3</sub> PO <sub>4</sub> ) electrolyte containing 0.66 wt% NH <sub>4</sub> F at (a) 30 V, (b) 40 V, (c) 50 and (d) 60 V for 60 min after annealed in argon atmosphere for 4 hr at 400 °C.   | 123 |

- Figure 4.39 FESEM images of CP-TiO<sub>2</sub> NT formed in 90:10 (EG: H<sub>3</sub>PO<sub>4</sub>) electrolyte containing 0.66 wt% NH<sub>4</sub>F for 1 hr at 60 V and subsequent annealed at 400 °C for 4 hr in N<sub>2</sub>. The inset shows the cross-section view of respective morphologies. 124
- Figure 4.40 PL spectra and their Gaussian fit band of CP-TiO<sub>2</sub> NT formed in 90:10 (EG: H<sub>3</sub>PO<sub>4</sub>) electrolyte containing 0.66 wt% NH<sub>4</sub>F for 1 hr at 60 V and subsequent annealed at 400 °C for 1 hr in (a) Ar and (b) N<sub>2</sub> atmosphere (excitation wavelength = 325 nm). 125
- Figure 4.41 Visible light decolorization of MO solution using CP-TiO<sub>2</sub> NT prepared in 90:10 (EG:H<sub>3</sub>PO<sub>4</sub>) electrolyte and pure EG containing 0.66 wt% NH<sub>4</sub>F 126
- Figure 4.42 FESEM images of CP-TiO<sub>2</sub> NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH<sub>4</sub>F, 1.0wt% H<sub>2</sub>O at 60 V, wet impregnation in (a) 0.01 M, (b) 0.02 M, (c) 0.03 M, (d) 0.04 M and (e) 0.05 M H<sub>3</sub>PO<sub>4</sub> for 60 min at 40 °C and subsequent annealed at 500 °C for 4 hr in Ar atmosphere. The insets show the cross-section view of respective morphologies. 127
- Figure 4.42 FESEM images of TiO<sub>2</sub> CP-NT formed by anodization of 0.1 mm thick Ti foil in EG solution containing 0.66 wt% NH<sub>4</sub>F, 1.0wt% H<sub>2</sub>O at 60 V, wet impregnation in (e) 0.05 M H<sub>3</sub>PO<sub>4</sub> for 60 min at 40 °C and subsequent annealed at 500 °C for 4 hr in Ar atmosphere. The insets show the cross-section view of respective morphologies. (continued) 129